

Supporting Information

Nanocavity-Confined Cu₂O in Porphyrin-based MOF for Steering CO₂ Electroreduction toward Hydrocarbons

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Materials: 4-Formylbenzoic acid, N,N-dimethylformamide (DMF), copper(II) sulfate pentahydrate ($\text{CuSO}_4 \cdot 5\text{H}_2\text{O}$), ascorbic acid, zirconyl chloride octahydrate ($\text{ZrOCl}_2 \cdot 8\text{H}_2\text{O}$), dichloroacetic acid, sodium hydroxide (NaOH), pyrrole, absolute ethanol ($\text{C}_2\text{H}_5\text{OH}$), acetone, and anhydrous methanol (CH_3OH) were purchased from Sinopharm Chemical Reagent Co., Ltd. High-purity gases (CO_2 and N_2 , purity $\geq 99.99\%$) were supplied by Nanjing Special Gas Co., Ltd., and ^{13}C -labeled carbon dioxide ($^{13}\text{CO}_2$, isotopic purity 99%) was obtained from Cambridge Isotope Laboratories (USA). Ultrapure water (resistivity $18.25 \text{ M}\Omega \cdot \text{cm}$) was prepared using a Fulham Ultra-Pure Water System (Qingdao, China). All chemicals and reagents were used as received without further purification.

Product Analysis: Gaseous reduction products were analyzed using a Shimadzu GC-2010 gas chromatograph equipped with a flame ionization detector (FID) and a thermal conductivity detector (TCD), using N_2 as the carrier gas. Liquid-phase products were quantified by ^1H nuclear magnetic resonance (NMR) spectroscopy (Bruker Avance II 400 MHz). For analysis, 0.4 mL of the electrolyte was mixed with 0.1 mL deuterated dimethyl sulfoxide (DMSO-d_6 , 99.99%).

Faradaic Efficiency (FE) Calculation

The Faradaic efficiency was calculated as follows¹:

$$FE = \frac{(N \times n \times F)}{Q} \times 100\%$$

where:

Q = total charge passed (Coulombs, C), F = Faraday constant (96485 C mol^{-1}),

N = moles of product generated, n = number of electrons required for product formation (e.g., H_2 : 2; CO : 2; CH_4 : 8; C_2H_4 : 12).

Theoretical calculation: All first-principles Density Functional Theory (DFT) calculations were performed to investigate the geometric and electronic structures of key reaction

intermediates (e.g., *CO₂, *COOH, *CO, *CHO, *OCH₃, *OHCCHO) and to evaluate the thermodynamic feasibility of the proposed pathways. The simulations were carried out using the Vienna Ab Initio Simulation Package (VASP) with the generalized gradient approximation (GGA-PBE) exchange-correlation functional^{2,3}, incorporating Grimme's DFT-D3 dispersion correction to account for van der Waals interactions. The projector-augmented wave (PAW) method was employed to describe core electrons⁴, while a plane-wave basis set with a kinetic energy cutoff of 400 eV was adopted for valence electrons. The calculations were performed with a kinetic energy cutoff of 450 eV and the Perdew-Burke-Ernzerhof (PBE) functional⁵ for exchange-correlation interactions. Gibbs free energy changes (ΔG) for each elementary step were computed as:

$$\Delta G = \Delta E_{\text{DFT}} + \Delta E_{\text{ZPE}} - T\Delta S + \Delta G_{\text{solv}} + \Delta G_{\text{pH}}$$

Where ΔE_{DFT} denotes the DFT total energy difference, ΔE_{ZPE} the zero-point energy correction (derived from vibrational frequency analysis), $T\Delta S$ the entropic contribution, ΔG_{solv} the solvation energy (implicit solvent model), and ΔG_{pH} the pH-dependent term adjusted via the Nernst equation. Transition states were located using the climbing-image nudged elastic band (CI-NEB) method, with convergence criteria of 10^{-4} eV for electronic self-consistency and 0.04 eV \AA^{-1} for ionic relaxation. DFT calculations were conducted using the Vienna Ab initio Simulation Package (VASP), employing plane-wave basis sets with the projector augmented-wave (PAW) pseudopotential method.

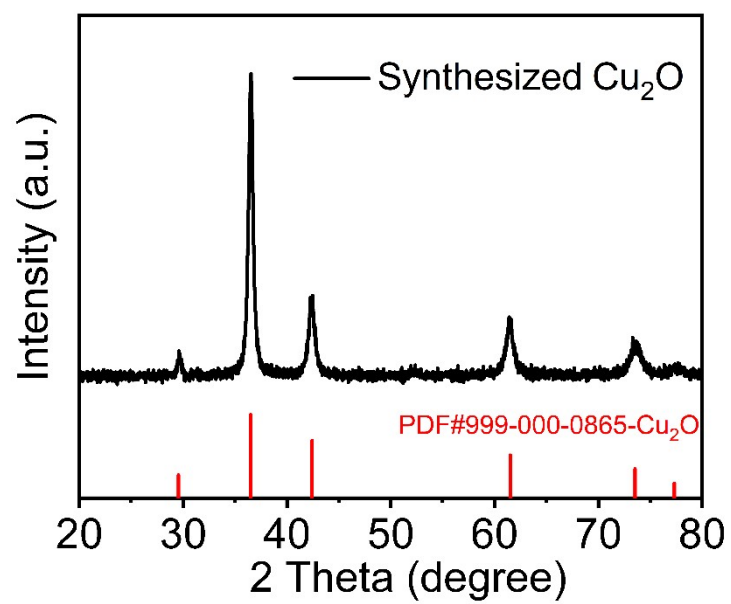


Fig. S1. PXRD pattern of the synthesized Cu₂O nanoparticles.

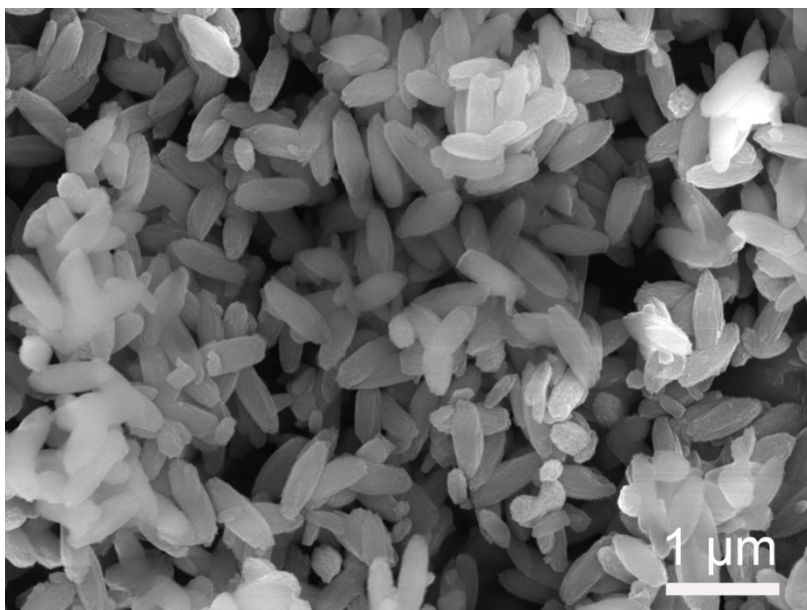


Fig. S2. SEM image of synthesized PCN-223.

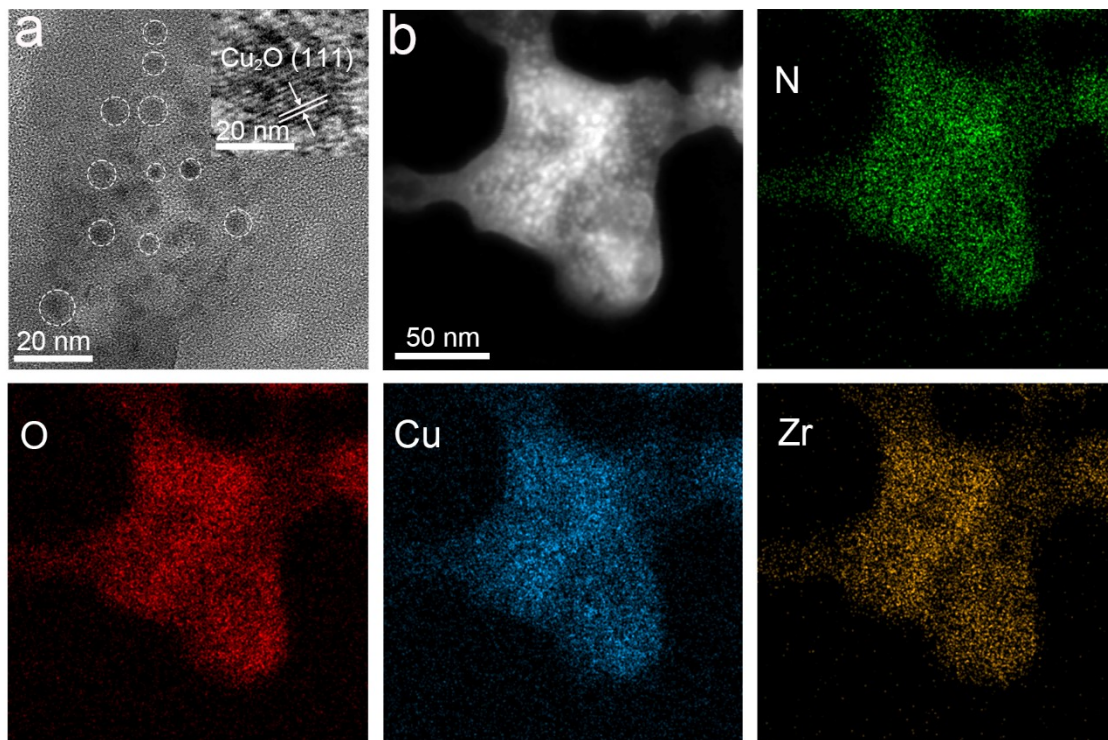


Fig. S3. Morphological characterization of ground Cu₂O@PCN-223. (a) HRTEM image, (b) STEM image and corresponding EDX elemental mapping.

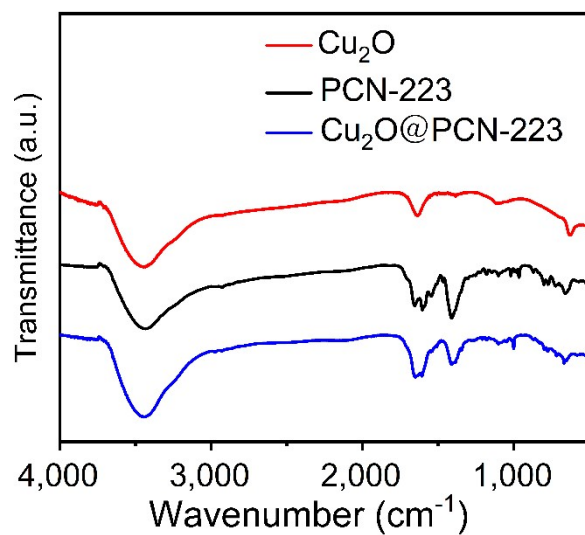


Fig. S4. FT-IR spectra of Cu₂O@PCN-223, PCN-223, and Cu₂O.

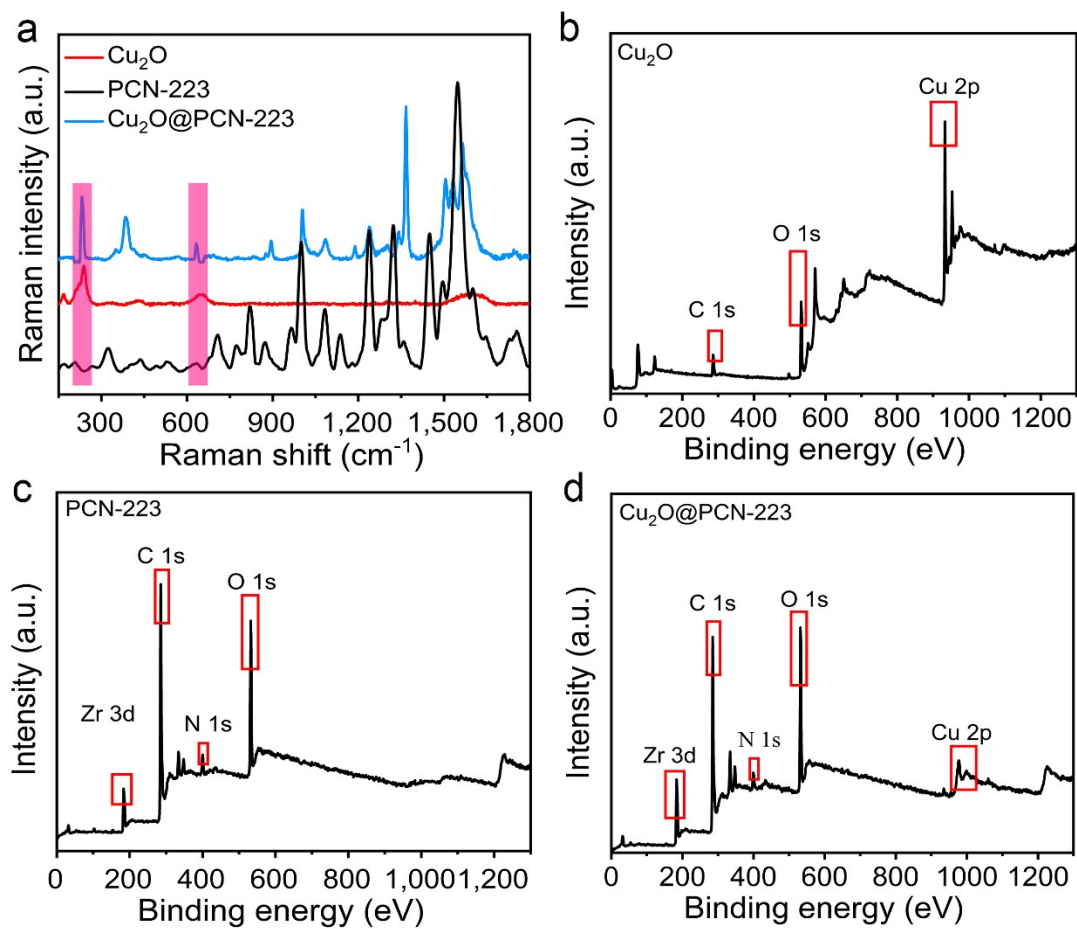


Fig. S5. Characterization of Cu₂O@PCN-223, PCN-223, and Cu₂O. (a) Raman spectra, (b) XPS spectrum of Cu₂O; (c) XPS spectrum of PCN-223; (d) XPS spectrum of Cu₂O@PCN-223.

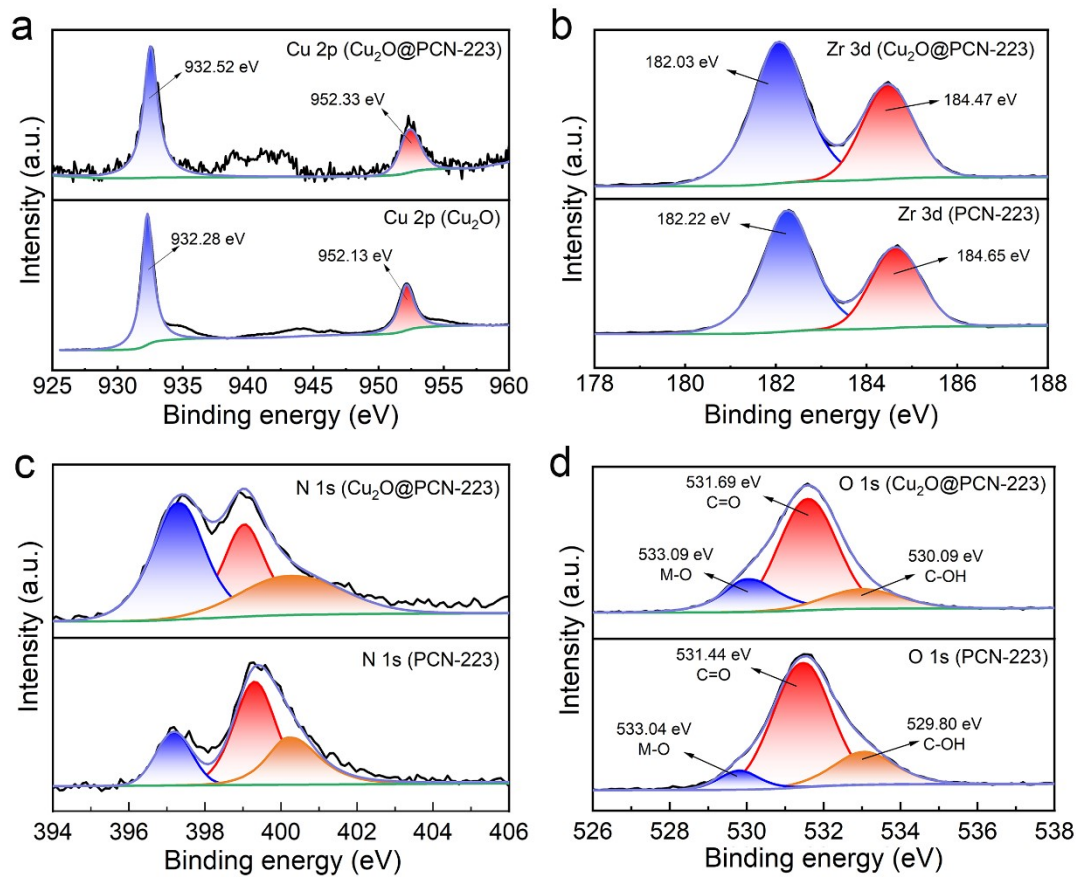


Fig. S6. High-resolution XPS spectra. (a) Cu 2p scan, (b) Zr 3d scan, (c) C 1s scan, (d) N 1s scan, and (e) O 1s scan.

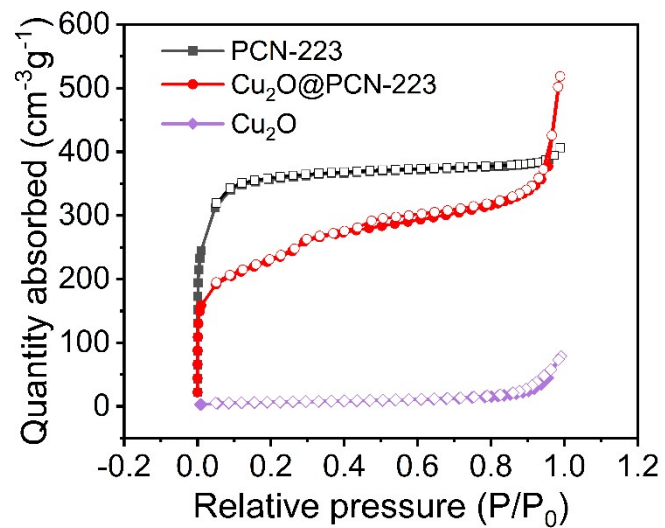


Fig. S7. N₂ adsorption-desorption isotherms of PCN-223, Cu₂O and Cu₂O@PCN-223.

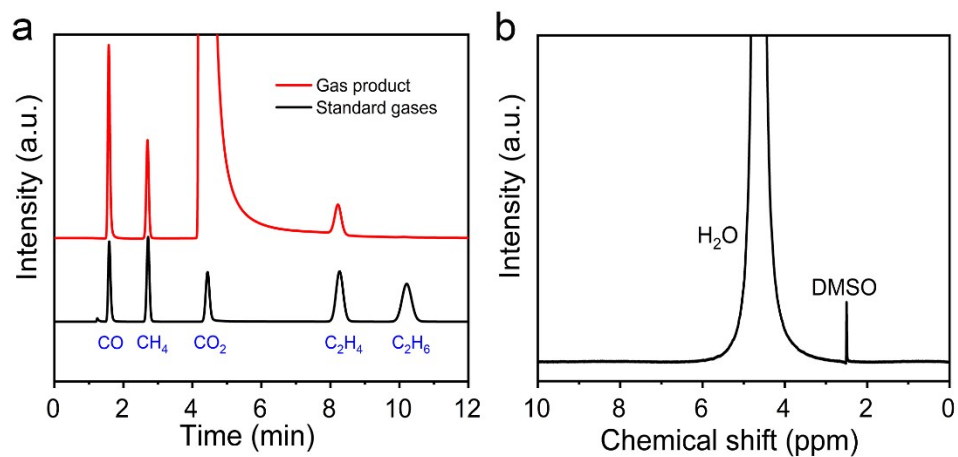


Fig. S8. Characterization of CO₂RR products catalyzed by Cu₂O@PCN-223. (a) Gas chromatogram, (b) ¹H NMR spectrum.

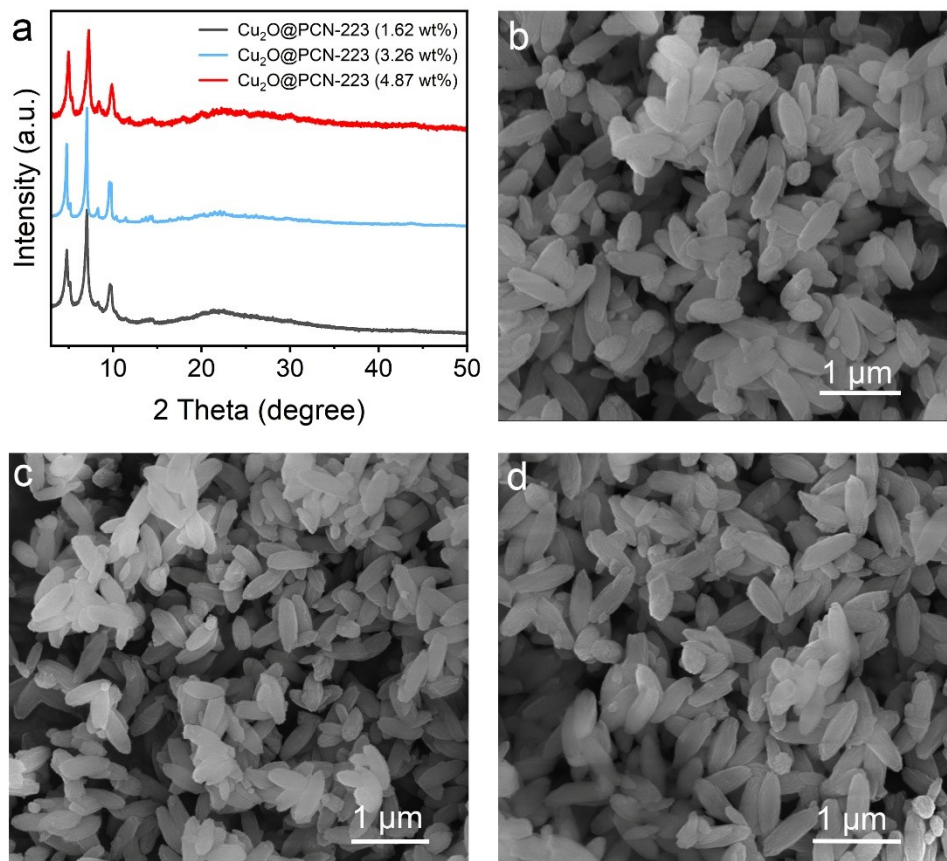


Fig. S9. Characterization of Cu₂O@PCN-223 with different Cu₂O loadings. (a) PXRD patterns. (b) SEM image of Cu₂O@PCN-223 (1.62 wt%). (c) SEM image of Cu₂O@PCN-223 (3.26 wt%). (d) SEM image of Cu₂O@PCN-223 (4.87 wt%).

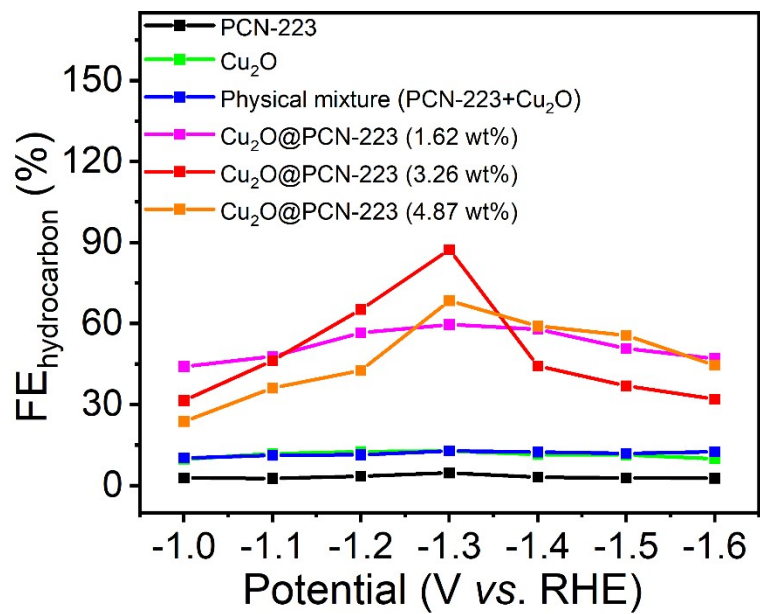


Fig. S10. Comparison of $FE_{\text{hydrocarbons}}$ between $\text{Cu}_2\text{O}@PCN-223$ and the reference sample.

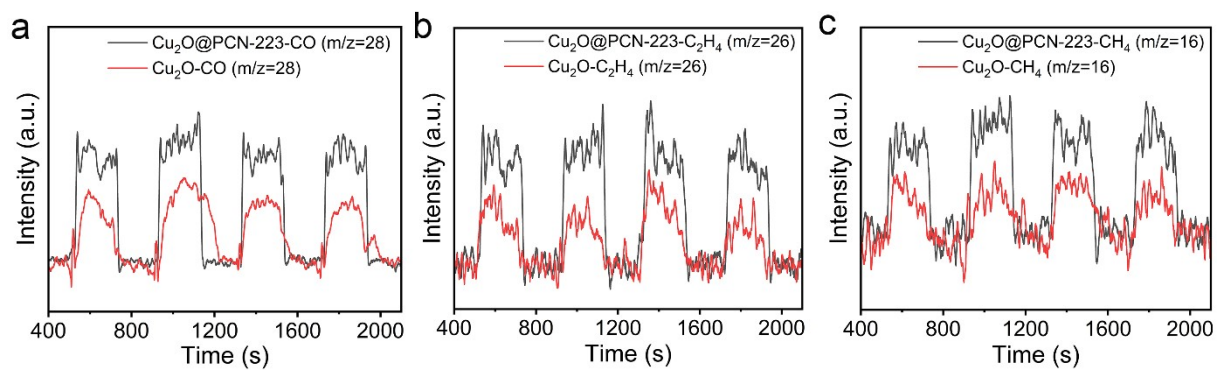


Fig. S11. Online differential electrochemical mass spectrometry (DEMS) of $\text{Cu}_2\text{O}@$ PCN-223 at a constant potential of -1.3 eV. (a) CO, (b) $\text{CH}_2=\text{CH}_2$, (c) CH_4 .

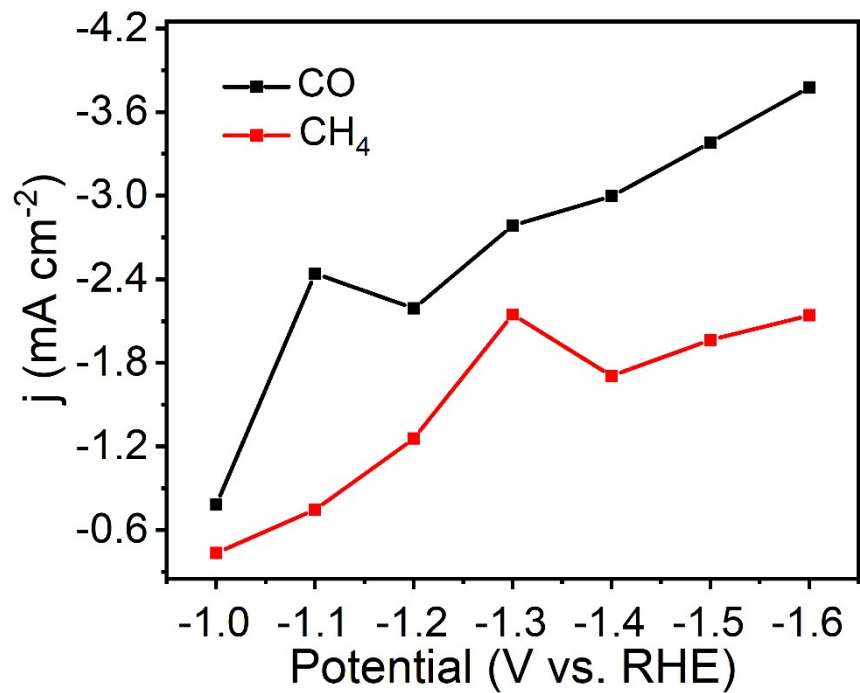


Fig. S12. Partial current densities of gaseous products obtained from PCN-223 at various applied potentials.

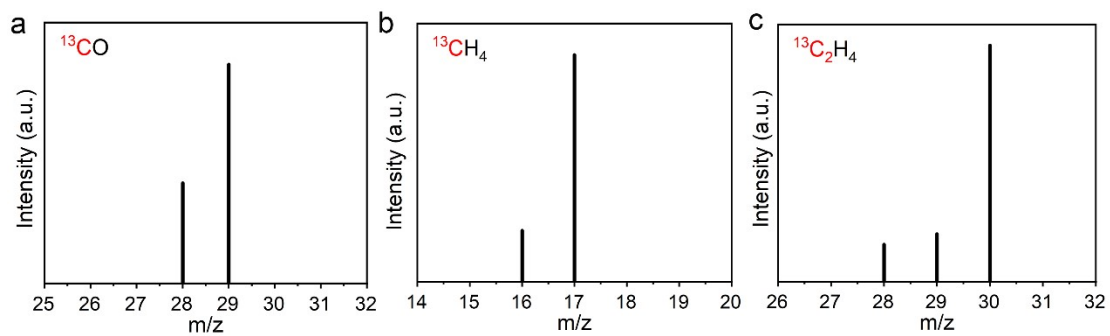


Fig. S13. Mass spectra for gas products. (a) ^{13}CO ; (b) $^{13}\text{CH}_4$; (c) $^{13}\text{C}_2\text{H}_4$.

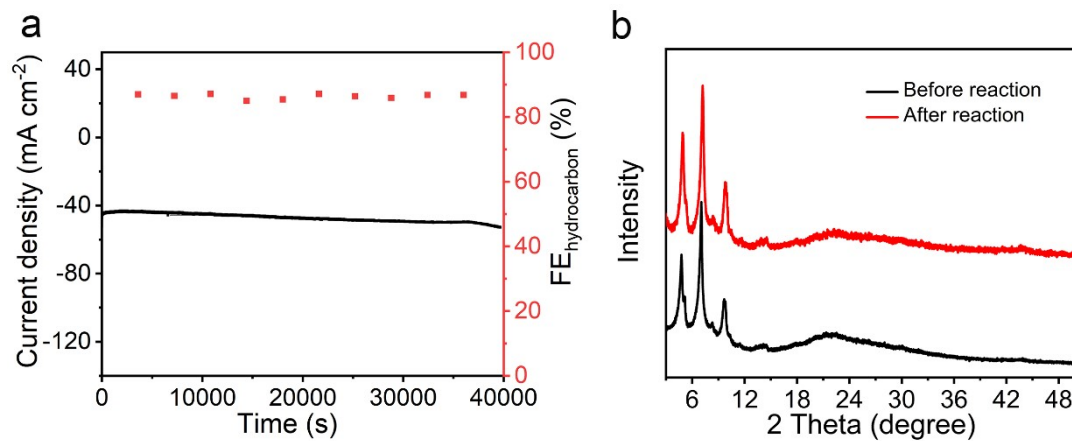


Fig. S14. Stability tests of Cu₂O@PCN-223. (a) Durability test of Cu₂O@PCN-223 at -1.3 V vs. RHE. b) PXRD patterns before and after reaction.

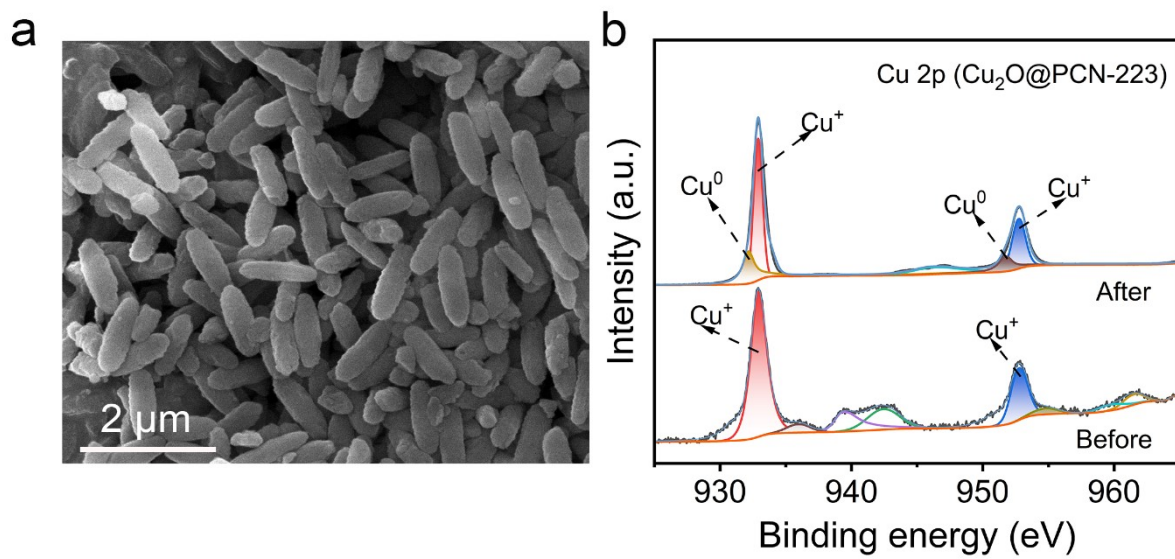


Fig. S15. (a) SEM image of Cu₂O@PCN-223 after the reaction. (a) XPS spectra of Cu₂O@PCN-223 before and after the reaction

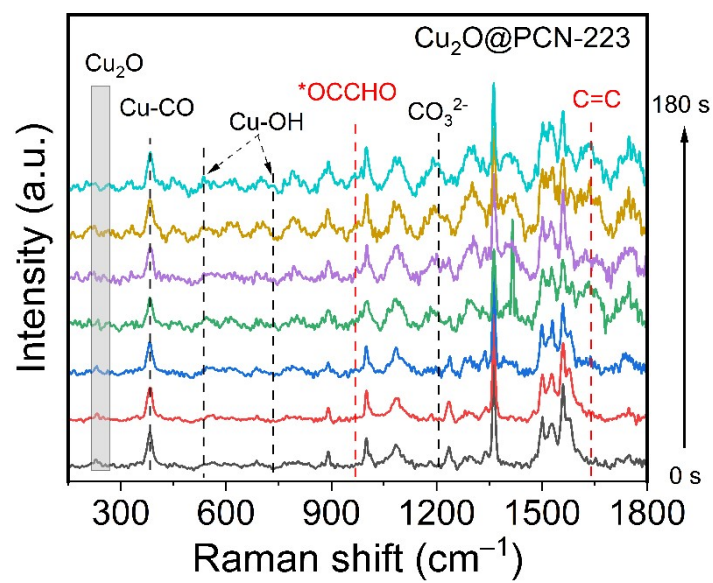


Fig. S16. In-situ Raman spectra of Cu₂O@PCN-223 at different time points

Table S1 BET surface area and pore volume of Cu₂O@PCN-223 and PCN-223 calculated from N₂ adsorption data.

Catalyst	Surface area (m ² /g)	Median pore width (Å)	Pore volume (cm ³ /g)
PCN-223	1065.56	5.871	0.546
Cu ₂ O	22.57	11.247	0.118
Cu ₂ O@PCN-223	791.04	5.822	0.339

Table S2 Copper (Cu) content in Cu₂O@PCN-223 with different cuprous oxide (Cu₂O) loadings analyzed by inductively coupled plasma (ICP) testing.

Samples	Cu (wt%)	Cu ₂ O (wt%)
Cu ₂ O@PCN-223	1.44	1.62
Cu ₂ O@PCN-223	2.90	3.26
Cu ₂ O@PCN-223	4.33	4.87

Table S3 Comparison of Cu₂O@PCN-223 with previously reported MOF electrocatalysts for CO₂RR to produce ethylene and methane

Catalyst	FE _{C₂H₄}	FE _{CH₄}	FE _{CH}	Potential	Stability	Ref
Cu ₂ O@PCN-223	48.7	38.6	87.3	-1.3 v	11 h	This work
Au-NN@PCN-222(Cu)	52.5	5.0	57.5	-1.2 v	10 h	6
CPFs	18.0	56.0	74.0	-1.4 v	2 h	7
Cu@ZIF-8	-	-	57.5	-0.7 v	6.5 h	8
Cu ₁ Ni-BDP	52.7	-	~52.7	-1.3 v	28 h	9
Lu-HHTP	-	77.0	77.0	-1.1 v	150 h	10
Cu ^{II} /ade-MOF	45 (1.4)	50 (1.6)	73.0	-1.6 v	8 h	11
S-HKUST-1	60.0	5.6	65.6	-1.3 v	480 h	12
Sn-THO	-	46.5	46.5	-1.6 v	80 h	13
2Bn-Cu@Uio-67	-	81.0	~81.0	-1.5 v	-	14
NNU-50	15.1	66.4	81.5	-1.0 v	4 h	15
KB@Cu ₃ (HITP) ₂	70.0	-	~70.0	-1.4 v	10 h	16
TEMPOL@HKUST-1	44.7	11.5	56.2	-1.8 v	8.3 h	17
Cu ₂ O@Cu-MOF	16.2	63.2	79.4	-1.7 v	1 h	18
BIC-145	28.0	6.7	34.7	-1.2 v	5 h	19
HATNA-Cu-MOF	-	78.0	~78.0	-1.5 v	12 h	20

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